

Laser-assisted micro/nanoscale material processing and in-situ diagnostics

David J. Jae-Seok Hwang¹, Costas P. Grigoropoulos²

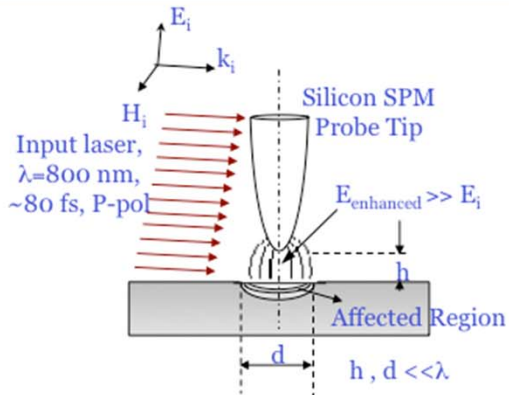
¹Department of Mechanical Engineering, State University of New
York, Stony Brook, NY, USA

²Department of Mechanical Engineering, University of California,
Berkeley, CA, USA

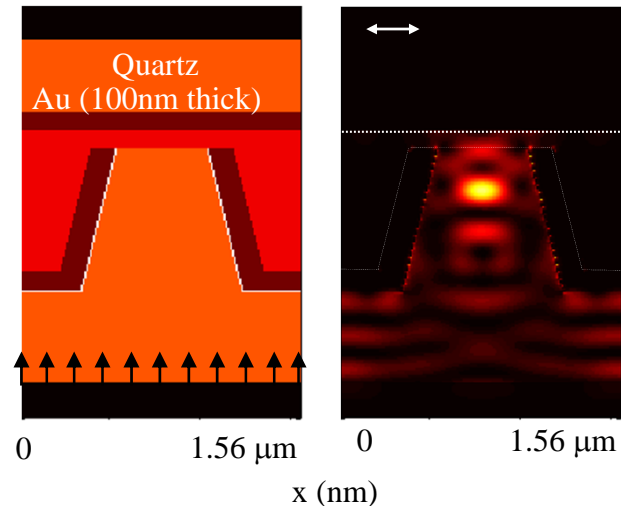
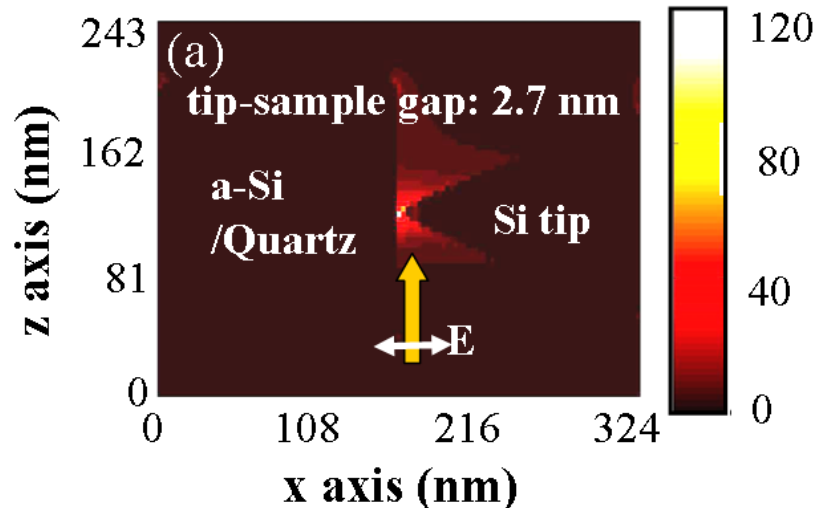
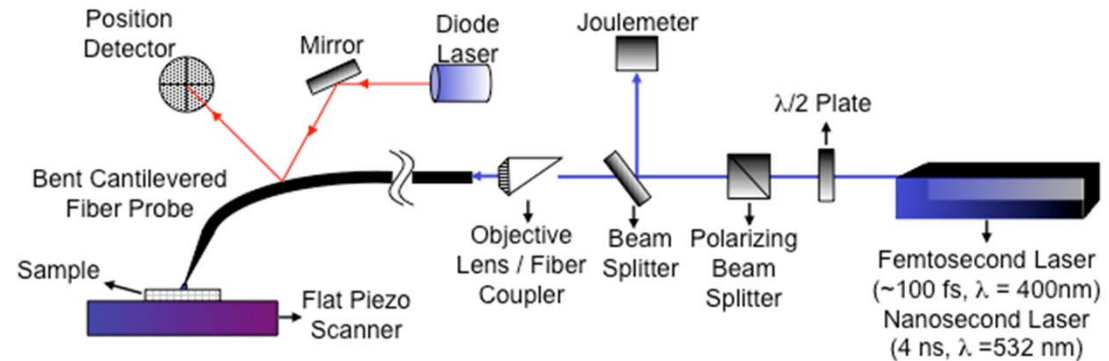
Introduction to optical near-field

Coupling of laser (light) illumination onto the sharp tip structures for sub-diffraction limit confinement

Apertureless NSOM



Apertured Fiber Coupled NSOM



D.J. Hwang, S.G. Ryu, N. Misra, H.J. Jeon, and C.P. Grigoropoulos, *Applied Physics A* (2009).

A. Chimmalgi, C. P. Grigoropoulos, and K. Komvopoulos, *J. Appl. Phys.* 97, 104319 (2005).

A. Chimmalgi, Choi, T.-Y., Grigoropoulos, C.P., and Komvopoulos, K., 2003, *Applied Physics Letters*, Vol. 82, pp. 1146–1148.

D.J. Hwang, Chimmalgi A., Grigoropoulos C. P., *J. Appl. Phys.* 99(4), 044905, 2006.

C.P. Grigoropoulos, and D.J. Hwang, in *Nanomanufacturing* (Chapter 9), ed. by Chen, American Scientific Publishers, In-press, 2009.

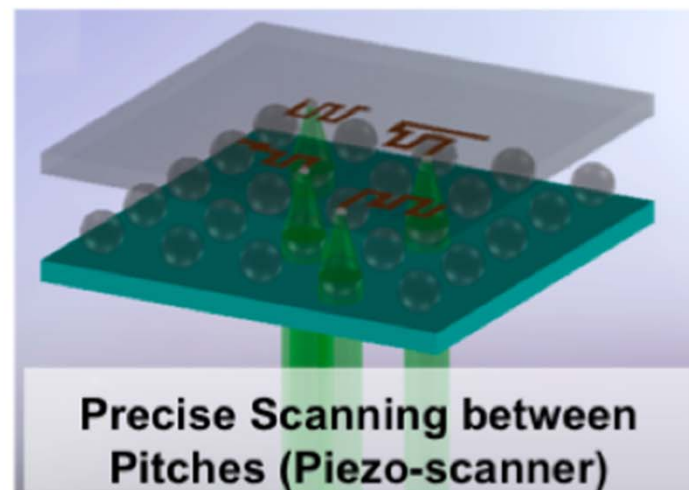
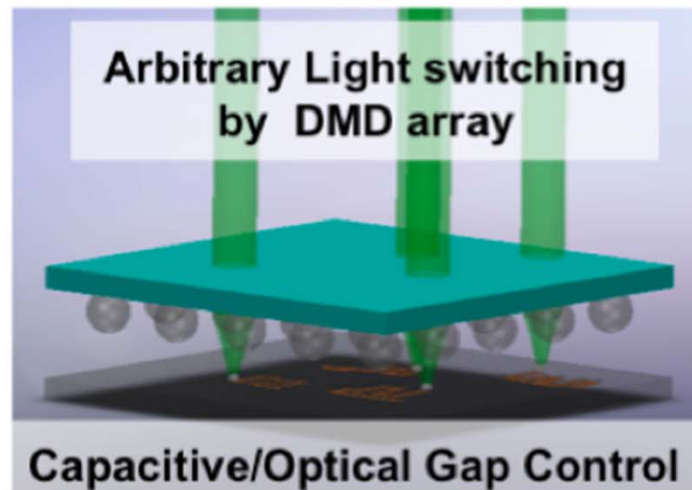
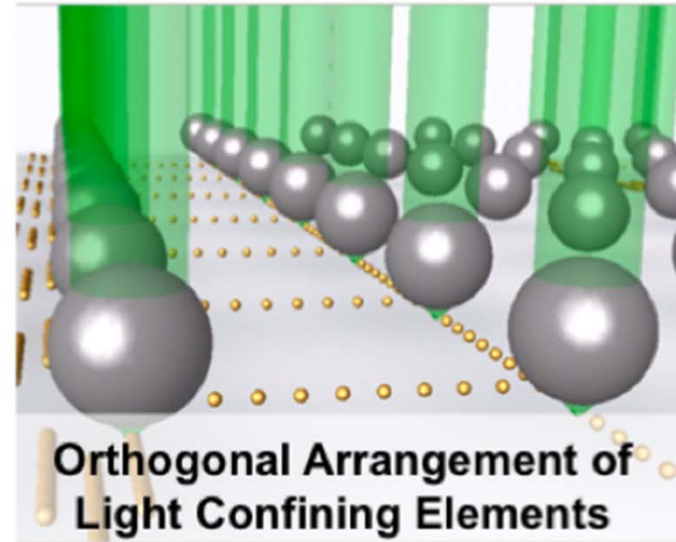
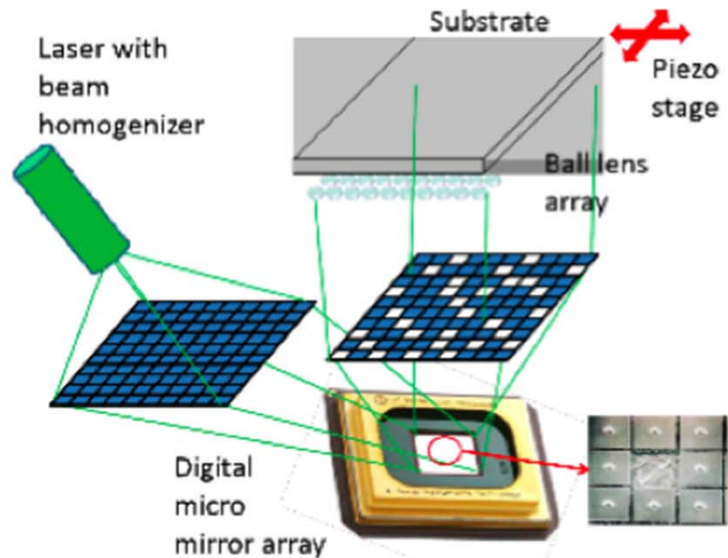
C.P. Grigoropoulos, A. Chimmalgi, D.J. Hwang, in *Laser ablation and its applications* (Chapter 19), Springer Series in optical sciences, New York, 2007.

C.P. Grigoropoulos, D.J. Hwang, A. Chimmalgi, *MRS Bulletin* (32) January Issue. (2007).

Scalable Nanomanufacturing by Optical Near-Field

Collaboration with Prof. Bauerle, Univ. of Linz, Austria

Use of Microsphere Array as Array of NSOM Probe



● H. Pan, D.J. Hwang, C.P. Grigoropoulos et. al., Small, 2010

● D.J. Hwang and C.P. Grigoropoulos, "Arbitrary pattern direct nanostructure fabrication methods and system," US20110318695 A1 (2011)

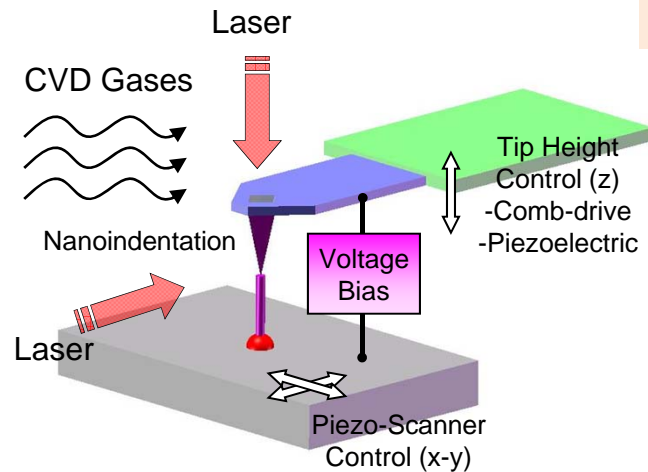


Laser Based Scalable Nanowire Growth

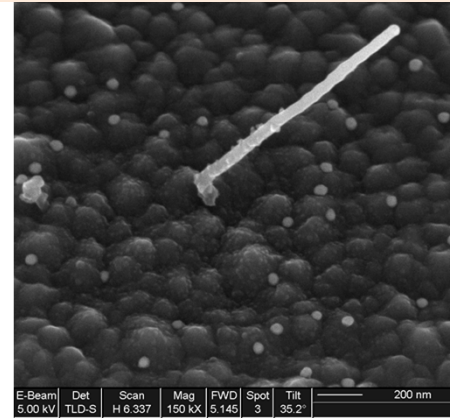
Nanofabrication by Tips coupled with Lasers

(Main PI: Prof. Grigoropoulos, UC Berkeley), Funded by Darpa, MTO

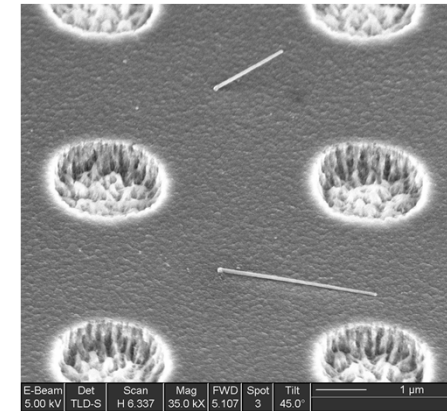
Demonstrated Localized Si & Ge Nanowire Synthesis



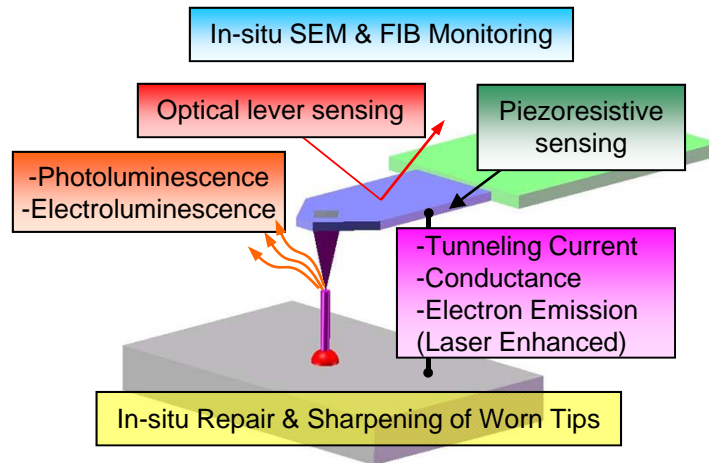
Processing Scheme



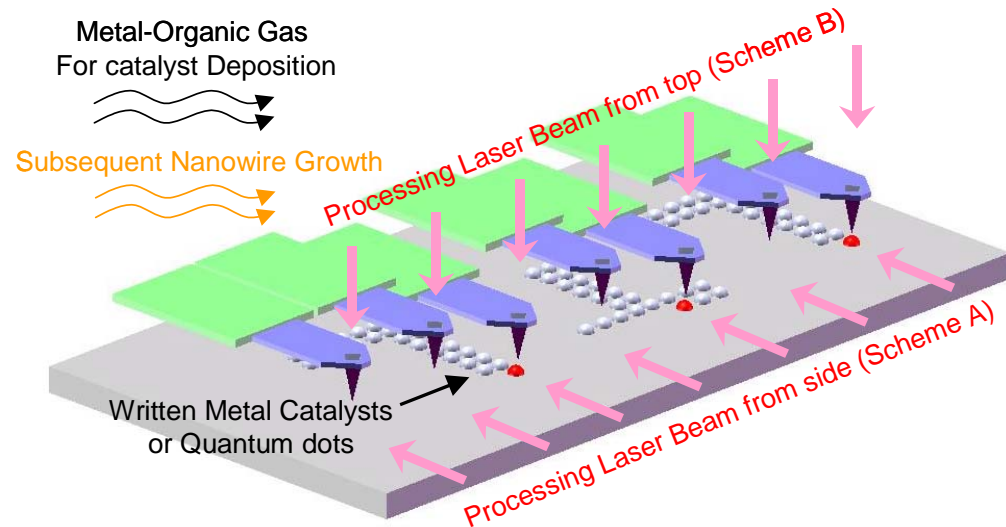
Single catalyst Selectivity



Heterogeneous growth

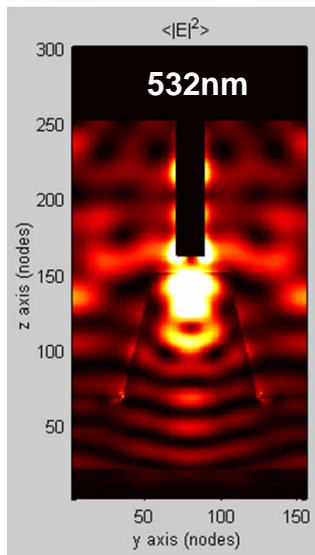
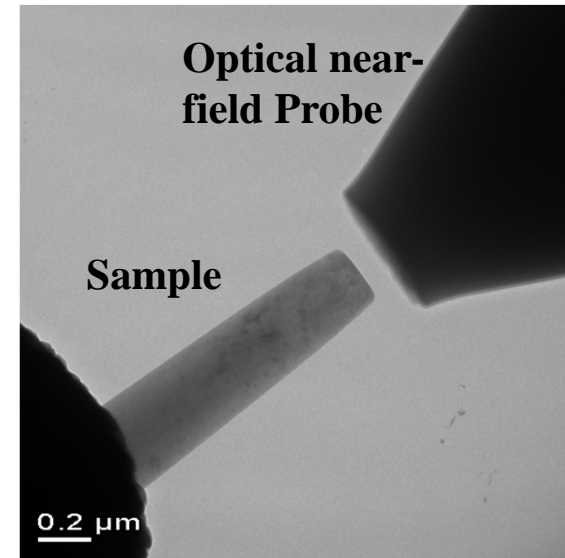
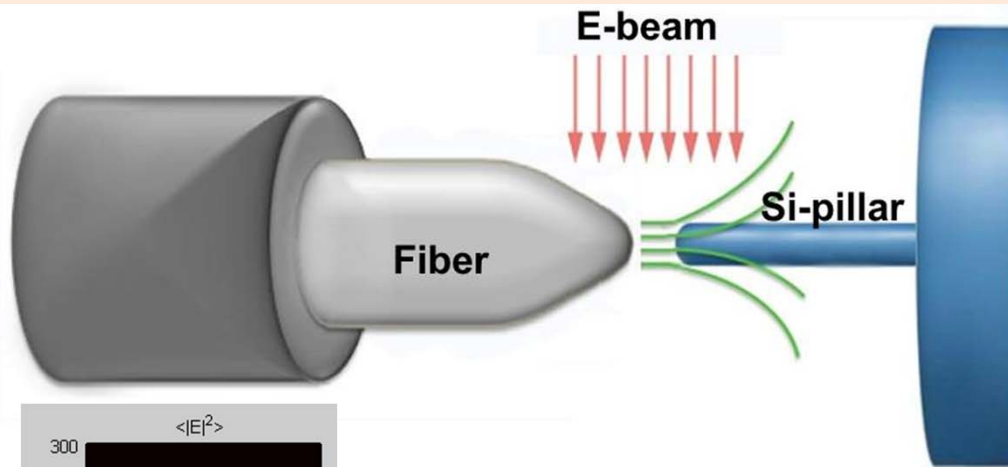


In-situ Monitoring Scheme

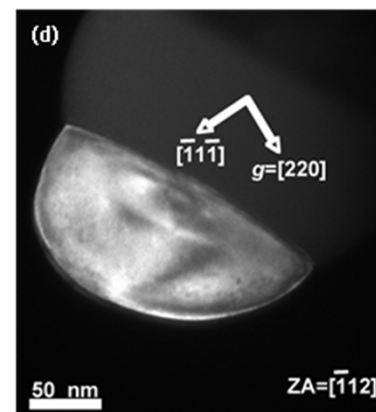
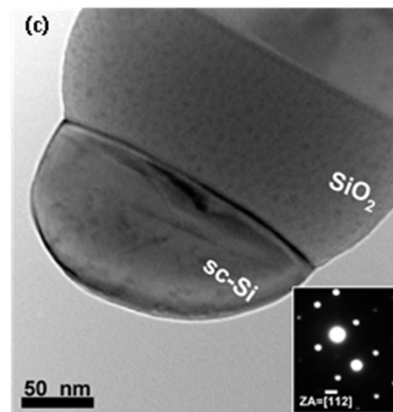


Parallel Processing Overall Configuration

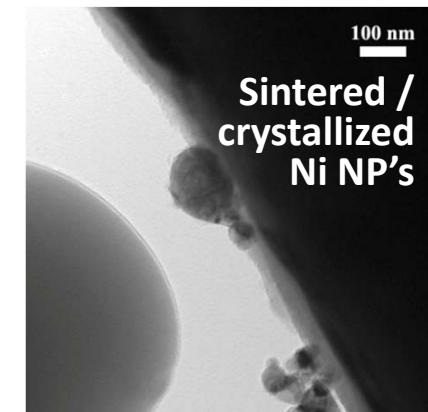
In-situ monitoring of laser processing in TEM



Optical near-field simulation



Achievement of Single Crystal Si by in-situ laser crystallization in TEM

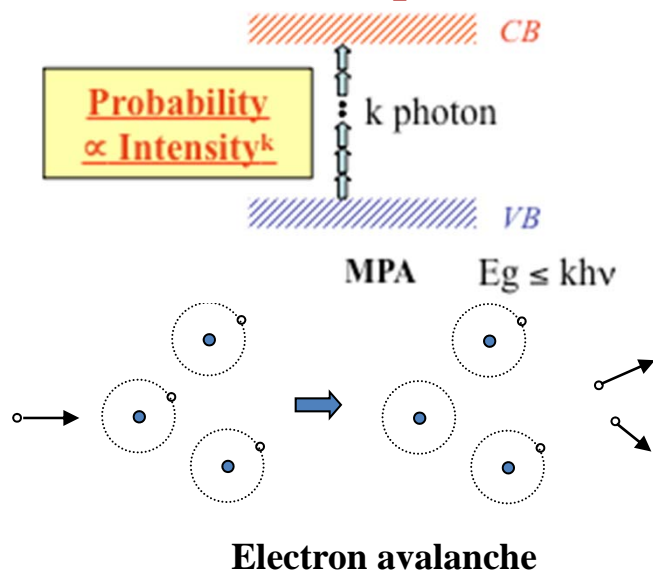


In-situ laser sintering process

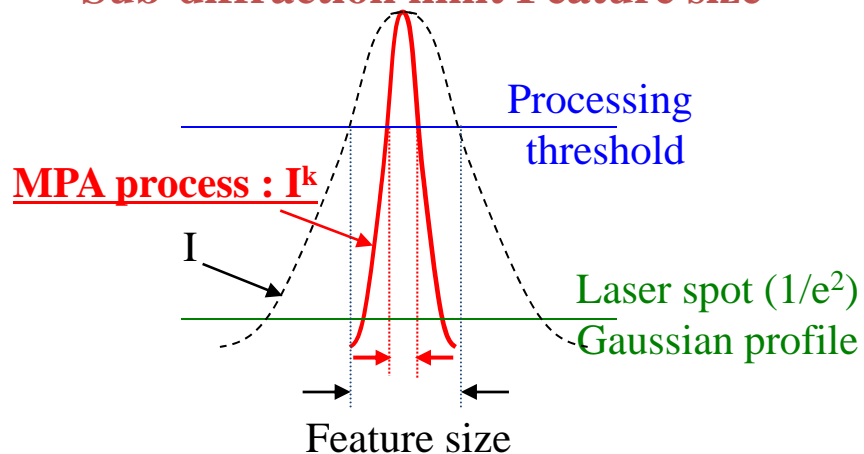
B. Xiang, D. J. Hwang, J. B. In, S.-G. Ryu, J.-H. Yoo, O. Dubon, A. M. Minor, and C. P. Grigoropoulos, "In Situ TEM Near-Field Optical Probing of Nanoscale Silicon Crystallization," *Nano Letters*, vol. 12, pp. 2524-2529 (2012).

Sub-diffraction limit feature by optical far-field

Multi-Photon Absorption Process

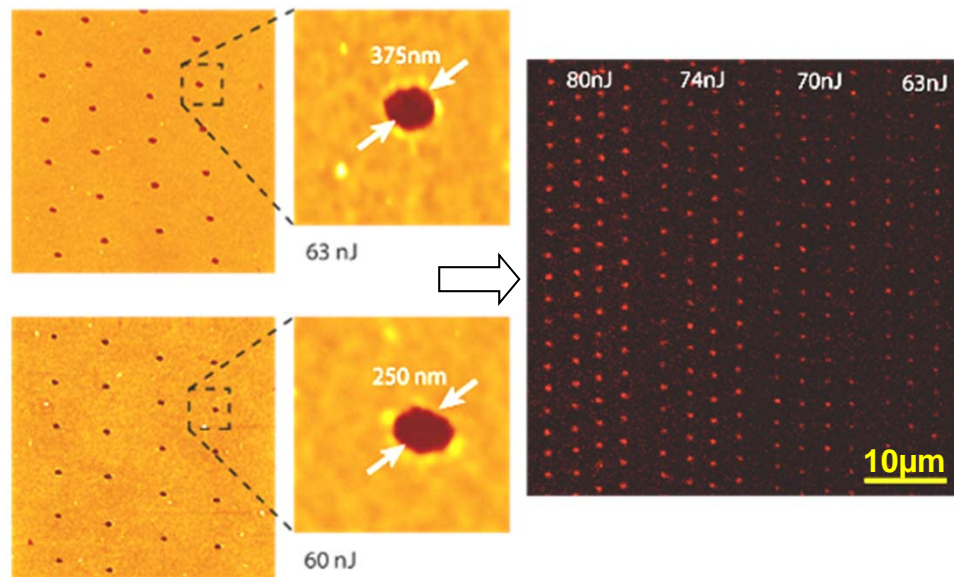
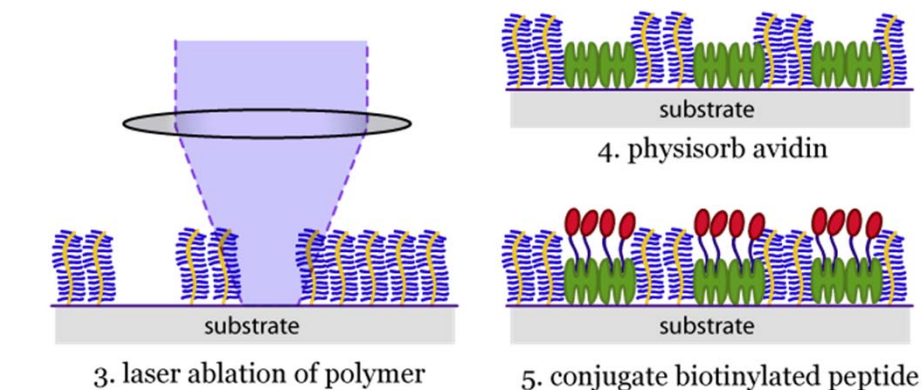


Sub-diffraction limit Feature size



→ Sub-diffraction limit sized features

Selective protein adhesion spot by fs laser peg (cell protecting) film on glass wafer (cell adhesive)



AFM images after laser process step

Confocal microscope images of adsorbed protein